

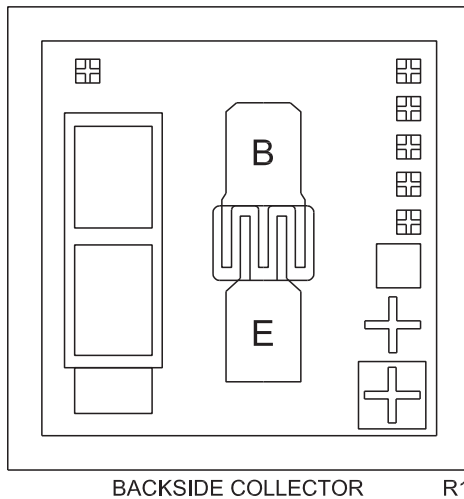
**PROCESS CP317V**  
**Small Signal Transistor**  
 NPN - RF Transistor Chip



**PROCESS DETAILS**

Process	EPITAXIAL PLANAR
Die Size	14.5 x 14.5 MILS
Die Thickness	7.1 MILS
Base Bonding Pad Area	2.4 x 2.2 MILS
Emitter Bonding Pad Area	2.4 x 2.2 MILS
Top Side Metalization	Al - 30,000Å
Back Side Metalization	Au - 18,000Å

**GEOMETRY**



**GROSS DIE PER 4 INCH WAFER**

53,788

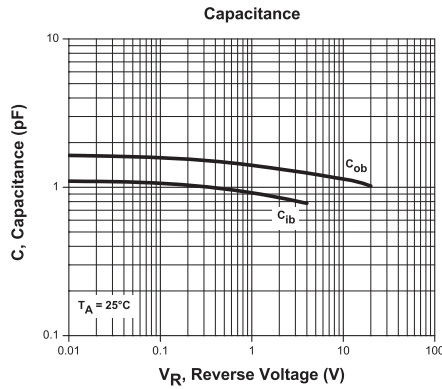
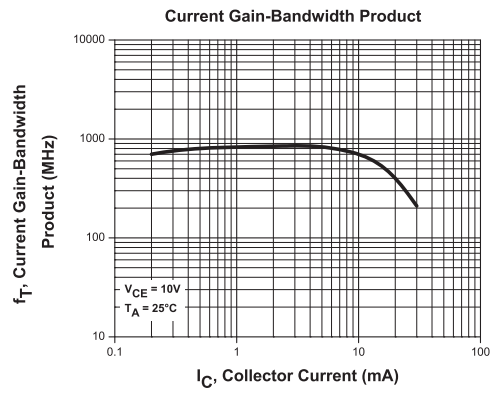
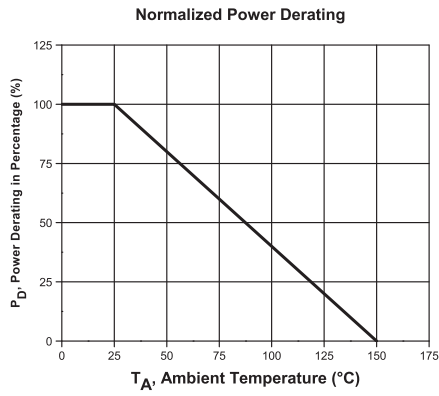
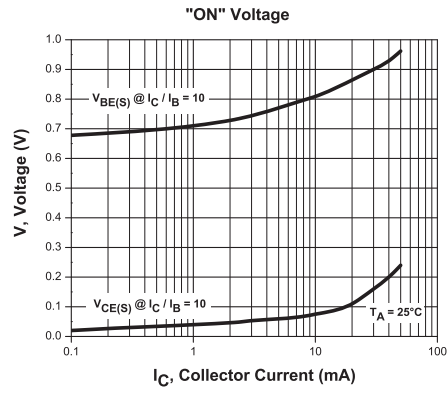
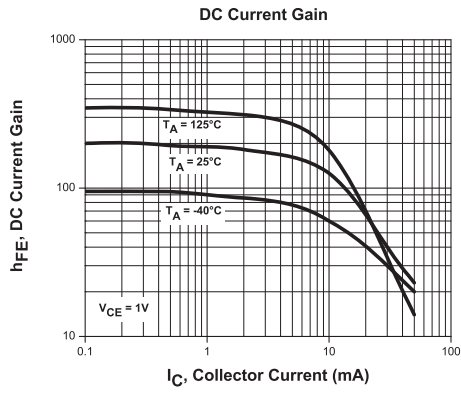
**PRINCIPAL DEVICE TYPES**

- CMPT918
- 2N918
- 2N2857
- 2N5179
- 2N5770
- BFY90
- PN3563
- PN3564

R0 (30-August 2011)

# PROCESS CP317V

## Typical Electrical Characteristics



R0 (30-August 2011)